

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

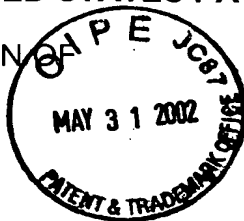
In re PATENT APPLICATION

GUI et al.

Application No.: 10/043,271

Filed: January 14, 2002

Title: LITHOGRAPHIC APPARATUS



Group Art Unit: 2851

Examiner: Unknown

Atty Dkt 81468/290598
C# M#

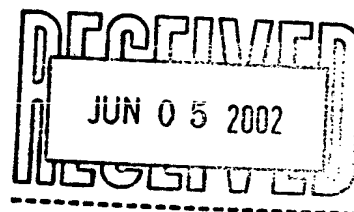
May 31, 2002

* * * * *

INFORMATION DISCLOSURE STATEMENT

Assistant Commissioner for Patents
Washington, D.C. 20231

Sir:



Attached is Form PTO-1449 listing the enclosed documents.

Should a first action on the merits have been issued on the same day or before this Information Disclosure Statement is filed, please accept this Information Disclosure Statement under Rule 97(c) and charge the requisite Rule 17(p) fee to our Deposit Account No. 03-3975, under Order No. 81468/290598 and proceed to consider this Information Disclosure Statement.

This IDS is intended to be in full compliance with the rules, but should the Examiner find any part of its required content to have been omitted, prompt notice to that effect is earnestly solicited, along with additional time under Rule 97(f) to enable Applicant to comply fully.

Consideration of the foregoing and enclosures plus the return of a copy of the enclosed Form PTO-1449 with the Examiner's initials in the left column per MPEP 609 are earnestly solicited along with an early action on the merits.

Respectfully submitted,

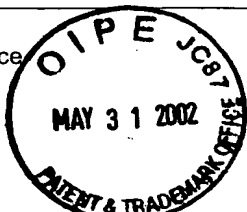
PILLSBURY WINTHROP LLP

By: 

Jack S. Barufka
Reg. No.: 37087
Tel. No.: 703.905.2012
Fax No.: 703.905.2500

1600 Tysons Boulevard
McLean, VA 22102
703.905.2000

FORM PTO-1449 (modified)
To: U.S. Department of Commerce
(PW FORM PAT-1449)
Patent and Trademark Office



Atty.
Dkt. No.

M#

290598

P-0224.010.US

Applicant: GUI et al.

Appln. No.: 10/043,271

Filing Date: January 14, 2002

Date: May 31, 2002

Page

1

of

1

Examiner: UNKNOWN

Group Art Unit: 2851

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

U.S. PATENT DOCUMENTS

Examiner's Initials*	Document Number	Date MM/YYYY	Name (Family Name of First Inventor)	Class	Sub Class	Filing Date (if appropriate)
	AR 4,798,470	01/1989	MORIYAMA et al.			
	BR 4,952,060	08/1990	INA et al.			
	CR 5,298,988	03/1994	EVERETT et al.			
	DR 5,361,132	11/1994	FARN			
	ER 5,874,190	02/1999	TANAKA			
	FR 5,929,997	07/1999	LIN			
	GR					
	HR					
	IR					
	JR					
	KR					
	LR					
	MR					
	NR					

FOREIGN PATENT DOCUMENTS

	Document Number	Date MM/YYYY	Country	Inventor Name	English Abstract		Translation Readily Available	
					Enclosed	No	Enclose	No
✓	OR 0 756 207 A3	01/1997	EUROPE	TANAKA et al.				
	PR							
	QR							
	RR							
	SR							

TECHNOLOGY CENTER 2800

JUN -3 2002

RECEIVED

OTHER (Including in this order Author, Title, Periodical Name, Date, Pertinent Pages, etc.)

✓	TR	Patent Abstract of Japan, JP11340120, published December 1999			
✓	UR	Patent Abstract of Japan, JP05144702, published June 1993			
✓	VR	Patent Abstract of Japan, JP3246923, published November 1991			
✓	WR	Patent Abstract of Japan, JP1164032, published June 1989			
✓	XR	Katagiri et al., "Novel alignment technique for 0.1-μm lithography using the wafer rear surface and canceling tilt effect," <i>Optical Engineering</i> 32(10):2344-2349 (1993)			
✓	YR	Everett et al., "Aligning lithography on opposite surfaces of a substrate," <i>Applied Optics</i> 31(34):7292-7294 (1992)			
	ZR				
	AAR				

Examiner

Date Considered:

*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.